



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No.	10/072,357	Confirmation No.	4288
First Inventor	Michael D. Kilgore	Filing Date	2/6/2002
Tech. Center/ Art Unit	2822	Examiner	Maria F. Guerrero
Title:	High Density Plasma Process For Optimum Film Quality And Electrical Results		
Docket No.:	NVS014 US	Customer No.:	34036

Santa Clara, California
December 9, 2003

COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

In response to Office Action dated July 9, 2003, please amend the above-identified application as follows.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.

12/17/2003 HALI11 00000013 10072357

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